

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Yoshiaki SUZUKI et al.

Confirmation No. 8295

Group Art Unit : 1794

Appln. No : 10/525,724

(National Stage of PCT/JP2003/011048)

Examiner : Zacharia

I.A. Filed : August 29, 2003

For : REPAIR MATERIAL HAVING AFFINITY WITH TISSUE ADHESIVE

**AMENDMENT UNDER 37 C.F.R. 1.114
IN RESPONSE TO FINAL OFFICE ACTION MAILED OCTOBER 22, 2008**

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, **Mail Stop AF**
Randolph Building
401 Dulany Street
Alexandria VA 22314

Sir:

This is in response to the Final Office Action mailed from the U.S. Patent and Trademark Office on October 22, 2008, which sets a three month shortened statutory period for response until January 22, 2009, the Advisory Action mailed February 3, 2009 in response to Applicants' Amendment to the Final Office Action filed January 22, 2009, and the Advisory Action mailed April 9, 2009 in response to Applicants' Reply to the Final Office Action filed March 23, 2009.

This submission is being filed as the submission of a Request for Continued Examination which is being concurrently filed herewith.

Applicants hereby request an extension of time for three months to extend the period for response until April 22, 2009, and are concurrently filing a formal Request for Extension of Time for three months accompanied by the government fee. If for any reason the formal Request for Extension of Time is not associated with the file at the

Patent and Trademark Office and/or if any extension of time and/or any fee is required to maintained the pendency of the application, such as for the entry of an Examiner's

Amendment, this an express request for any necessary extension of time and/or fee to maintain the pendency of the application, and authorization to charge any necessary fee to Deposit Account No. 19-0089.

Amendments to the Specification begin on page 3 of this paper.

Amendments to the Claims begin on page 4 of this paper.

Remarks begin on page 7 of this paper.

Reconsideration and allowance of the application are respectfully requested.